

Stability of Phases in the Si-C-N-O System

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The stability of the phases in equilibrium is calculated for the Si-C-N-O system in order to analyze and predict the reactions in ceramic whisker formation and sintering of silicon nitride composites. Equilibria among SiC, Si₃N₄, Si₂N₂O, SiO₂, Si, and the gas phase are evaluated at different carbon activities, nitrogen pressures, and temperatures. Phase stability diagrams are constructed as a function of nitrogen and oxygen pressures for two levels of carbon activity. Silicon nitride becomes a stable phase with increasing nitrogen pressure or decreasing carbon activity and temperature, whereas silicon carbide becomes a dominant phase at lower nitrogen pressures or at higher temperatures when carbon activity is unity. The maximum sintering temperature of the SiC/Si₃N₄ composite is higher with an elevated nitrogen pressure or a reduced carbon activity.

I. Introduction

BOTH silicon nitride and silicon carbide are advanced engineering materials that are expected to be used in a wide range of applications. The stability of the phases in the Si-C-N-O system, including the gas phase, is calculated to predict and analyze the reactions in the formation and sintering of silicon nitride and silicon carbide. Since the sintering or the formation of powders and whiskers of silicon nitride is usually performed with either a graphite resistance furnace or a nongraphite furnace under a nitrogen/argon atmosphere, carbon activity and nitrogen pressure are the main variables in this calculation. Other important factors are oxygen partial pressure and temperature. Temperature is limited to a practical range which is commonly applied for sintering. The oxygen partial pressure in the gas phase controls the formation of certain phases such as silicon oxynitride and silica. The equilibrium oxygen partial pressure and the partial pressure of silicon monoxide (SiO)— which controls the high-temperature decomposition of silicon nitride— can be determined by thermodynamic calculations.

Phase equilibria in the system based on silicon nitride have been calculated by Weiss *et al.*^{1,2} The Si-N-O, Si-C-O, Si-C-N, and Si-C-N-O systems have been calculated by the Lukas program³ and the Eriksson program.⁴ These calculations cover a high-temperature range and a wide range of compositions. The gas-phase compositions and the phases in equilibrium with the gases are summarized in Table 3 of Ref. 1. Weiss *et al.* did not include carbon activity as a variable in their calculations. Therefore, the equilibrium gas compositions in the systems without graphite should be considered separately from those calculated for a carbon activity of unity.

To clearly demonstrate a relationship between the solid and gas phases, the solid phase stability is calculated as a function of gas composition and pressure at known temperatures and carbon activities.

II. Stability of Phases

(1) Phases in Equilibrium

The equilibrium phases in the system are β-Si₃N₄, Si₂N₂O, β-SiC, SiO₂ (cristobalite), Si, C, and a gas phase. The main components of the gas phase are N₂, O₂, SiO, and CO/CO₂.

Two carbon activity levels, $a_c = 1$ and 10^{-4} , which are referred to solid graphite as a standard state, are used for the calculation. The temperature is from 1573 to 2073 K. This is a fairly close approximation of the actual experimental conditions; for example, when a graphite crucible or furnace is used for Si₃N₄ sintering, the carbon activity would be unity or very close to unity, whereas it would be very low in an elevated pressure, nongraphite furnace.

(2) Three-Phase Equilibria

Equilibrium between two solid phases and a gas phase is calculated first. For instance, equilibrium between Si₃N₄ and SiC is expressed as follows for the present temperature range:



The ratio of the activities of Si₃N₄ and SiC, which are referred to solid Si₃N₄ and SiC, respectively, is written as

$$\log \left(\frac{a_{\text{SiC}}^3}{a_{\text{Si}_3\text{N}_4}} \right) = \log K_1 + 3 \log a_c - 2 \log p_{\text{N}_2} \quad (I)$$

where K_1 is the equilibrium constant of Eq. (1). Since Si₃N₄ and SiC form almost no solid solution, their activities are either unity or less than unity—the activity of unity showing that the species exists as a solid phase, whereas an activity of less than unity shows nonexistence of the solid phase of that species. There are three possibilities for Eq. (I): If $\log (a_{\text{SiC}}^3/a_{\text{Si}_3\text{N}_4}) = 0$, then $a_{\text{SiC}} = a_{\text{Si}_3\text{N}_4} = 1$; if $\log (a_{\text{SiC}}^3/a_{\text{Si}_3\text{N}_4}) > 0$, then $a_{\text{SiC}} = 1$ and $a_{\text{Si}_3\text{N}_4} < 1$; and if $\log (a_{\text{SiC}}^3/a_{\text{Si}_3\text{N}_4}) < 0$, then $a_{\text{SiC}} < 1$ and $a_{\text{Si}_3\text{N}_4} = 1$. In the first case, the Si₃N₄ and SiC phases coexist, whereas SiC is the stable phase in the second case and Si₃N₄ is the stable phase in the third case.

Equation (I) is calculated as a function of temperature for $a_c = 1$ and $p_{\text{N}_2} = 1$ and 10 atm (0.10 and 1.01 MPa) as shown in Fig. 1. At $p_{\text{N}_2} = 1$ atm (0.10 MPa), Si₃N₄ and SiC are in equilibrium at 1647 K. SiC is stable at higher temperatures, and Si₃N₄ is stable at lower temperatures, whereas the temperature for equilibrium between the two phases moves upward to 1809 K when the nitrogen pressure is increased to 10 atm (1.01 MPa). This information can be applied as a guideline to the sintering of Si₃N₄ ceramic or SiC/Si₃N₄ composite.

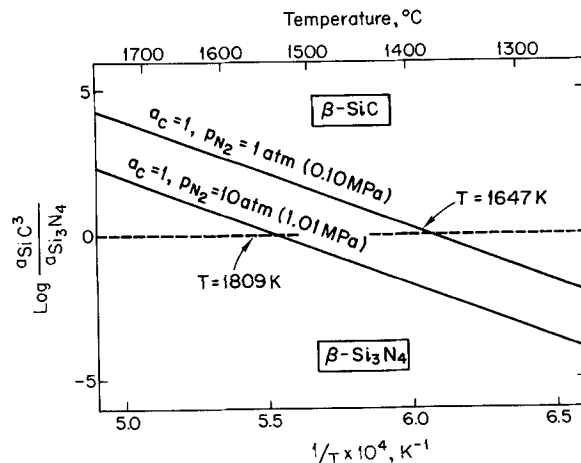


Fig. 1. Equilibrium between β-SiC and β-Si₃N₄ at $a_c = 1$ with $p_{\text{N}_2} = 1$ and 10 atm (0.10 and 1.01 MPa).

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Table I. Equilibrium Reactions in Si-C-N-O System

Reaction	
(1)	$\beta\text{-Si}_3\text{N}_4 + 3\text{C}(s) = 3\beta\text{-SiC} + 2\text{N}_2(g)$
(2)	$4\beta\text{-Si}_3\text{N}_4 + 3\text{O}_2(g) = 6\text{Si}_2\text{N}_2\text{O}(s) + 2\text{N}_2(g)$
(3)	$\beta\text{-Si}_3\text{N}_4 + 3\text{O}_2(g) = 3\text{SiO}_2(c) + 2\text{N}_2(g)$
(4)	$2\text{Si}_2\text{N}_2\text{O}(s) + 4\text{C}(s) = 4\beta\text{-SiC} + \text{O}_2(g) + 2\text{N}_2(g)$
(5)	$2\text{Si}_2\text{N}_2\text{O}(s) + 3\text{O}_2(g) = 4\text{SiO}_2(c) + 2\text{N}_2(g)$
(6)	$\text{SiO}_2(c) + \text{C}(s) = \beta\text{-SiC} + \text{O}_2(g)$
(7)	$3\text{Si}(l) \text{ or } (s) + 2\text{N}_2(g) = \beta\text{-Si}_3\text{N}_4$
(8)	$4\text{Si}(l) \text{ or } (s) + 2\text{N}_2(g) + \text{O}_2(g) = 2\text{Si}_2\text{N}_2\text{O}(s)$
(9)	$\text{Si}(l) \text{ or } (s) + \text{O}_2(g) = \text{SiO}_2(c)$

Table II. Standard Free Energies of Formation of Condensed Phases

Species	$\Delta_f G^\circ$ (kJ/mol)*	Reference
$\beta\text{-Si}_3\text{N}_4$	$-925.2 + 0.450T$	6
$\text{Si}_2\text{N}_2\text{O}$	$-658.3 + 0.131T$	6
$\beta\text{-SiC}$	$-72.832 + 0.007T$	5
$\text{SiO}_2(c)$	$-900.384 + 0.171T$	5
$\text{Si}(l)$	$-42.825 + 0.0647T - 0.24 \times 10^{-4} T^2$	5

*Standard states are Si(s), C(s), $p_{\text{N}_2} = 1$ atm (0.10 MPa), and $p_{\text{O}_2} = 1$ atm (0.10 MPa).

Table III. Invariant Points at Given a_c and Temperature

a_c	T (K)	$\text{Si}_3\text{N}_4/\text{Si}_2\text{N}_2\text{O}/\text{SiC}$ (atm (MPa))	$\text{SiO}_2/\text{Si}_2\text{N}_2\text{O}/\text{SiC}$ (atm (MPa))
1	1673	$p_{\text{N}_2} = 10^{0.17} (10^{-0.82})$ $p_{\text{O}_2} = 10^{-20.13} (10^{-21.12})$	$p_{\text{N}_2} = 10^{-1.26} (10^{-2.25})$ $p_{\text{O}_2} = 10^{-17.27} (10^{-18.26})$
1	1973	$p_{\text{N}_2} = 10^{1.85} (10^{0.86})$ $p_{\text{O}_2} = 10^{-18.62} (10^{-19.61})$	$p_{\text{N}_2} = 10^{-0.79} (10^{-1.78})$ $p_{\text{O}_2} = 10^{-13.34} (10^{-14.33})$
a_c	T (K)	$\text{Si}_3\text{N}_4/\text{Si}_2\text{N}_2\text{O}/\text{Si}(s) \text{ or } (l)$ (atm (MPa))	$\text{SiO}_2/\text{Si}_2\text{N}_2\text{O}/\text{Si}(s) \text{ or } (l)$ (atm (MPa))
10^{-4}	1673	$p_{\text{N}_2} = 10^{-2.69} (10^{-3.68})$ $p_{\text{O}_2} = 10^{-22.04} (10^{-23.03})$	$p_{\text{N}_2} = 10^{-4.12} (10^{-5.11})$ $p_{\text{O}_2} = 10^{-19.18} (10^{-20.17})$
10^{-4}	1973	$p_{\text{N}_2} = 10^{-0.15} (10^{-1.14})$ $p_{\text{O}_2} = 10^{-19.75} (10^{-20.74})$	$p_{\text{N}_2} = 10^{-2.65} (10^{-3.64})$ $p_{\text{O}_2} = 10^{-14.58} (10^{-15.57})$

Other equilibria, such as $\text{Si}_3\text{N}_4/\text{Si}_2\text{N}_2\text{O}$, $\text{Si}_3\text{N}_4/\text{SiO}_2$, $\text{Si}_2\text{N}_2\text{O}/\text{SiO}_2$, $\text{Si}_2\text{N}_2\text{O}/\text{SiC}$, SiC/SiO_2 , $\text{Si}/\text{Si}_3\text{N}_4$, $\text{Si}/\text{Si}_2\text{N}_2\text{O}$, and Si/SiO_2 are calculated by the same principle. The equilibrium reactions in the Si-C-N-O system in the temperature range concerned in this study are summarized in Table I. The standard free energies of formation are obtained mainly from JANAF Tables.⁵ The free energies of formation of $\beta\text{-Si}_3\text{N}_4$ and $\text{Si}_2\text{N}_2\text{O}$ are not listed in JANAF. These two phases are important phases in the Si-C-N-O system and their free energies should be consistent with each other. Two values are accepted from Hendry.⁶ The standard free energies of formation of the solid phases are summarized in Table II.

(3) Four-Phase Equilibria

When three solid phases and a gas phase are in equilibrium, the number of degrees of freedom determined from the phase rule is two. Combining the equations shown in Table II, phase stability is calculated at $a_c = 1$ and 10^{-4} and at temperatures 1673 and 1973 K. For instance, the $\text{Si}_3\text{N}_4/\text{Si}_2\text{N}_2\text{O}/\text{SiC}/\text{gas}$ -phase equi-

librium is calculated as follows from reactions (1) and (2) in Table I:

$$\log K_1 + 3 \log a_c - 2 \log p_{\text{N}_2} = -36909.385/T + 22.406 + 3 \log a_c - 2 \log p_{\text{N}_2} = 0 \quad (\text{II})$$

$$\log K_2 - 2 \log p_{\text{N}_2} + 3 \log p_{\text{O}_2} = 13004.648/T + 52.959 - 2 \log p_{\text{N}_2} + 3 \log p_{\text{O}_2} = 0 \quad (\text{III})$$

At known a_c and temperature, the oxygen and nitrogen pressures are calculated for this invariant point. Other invariant points are also calculated as summarized in Table III.

Examples of calculated stability diagrams are shown in Figs. 2 and 3. Figure 2 shows the stability diagram for $a_c = 1$ and $T = 1673$ and 1973 K, which are shown with solid and dashed lines, respectively. The most significant feature of the diagram is the effect of nitrogen pressure and temperature on the phase sta-

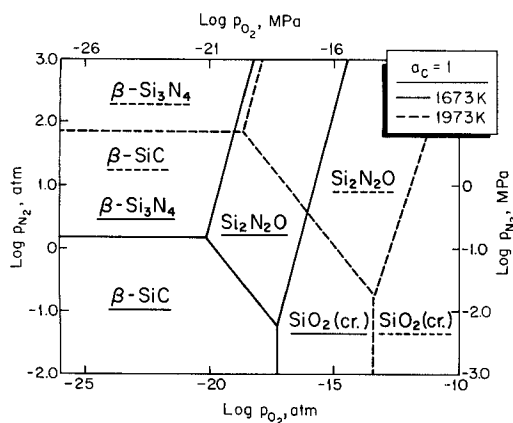


Fig. 2. Phase stability diagram as a function of partial pressures of nitrogen and oxygen at $a_c = 1$, $T = 1673$ and 1973 K.

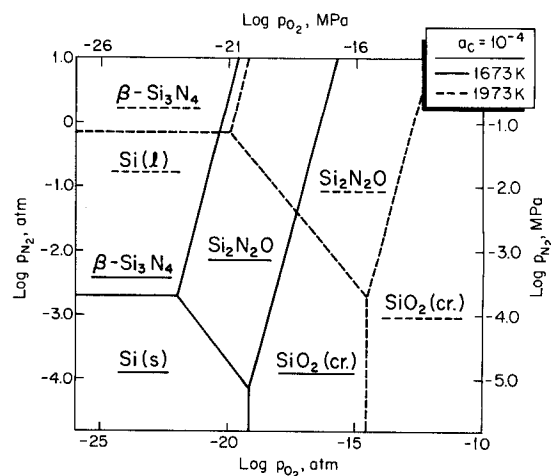


Fig. 3. Phase stability diagram as a function of partial pressures of nitrogen and oxygen at $a_c = 10^{-4}$, $T = 1673$ and 1973 K.

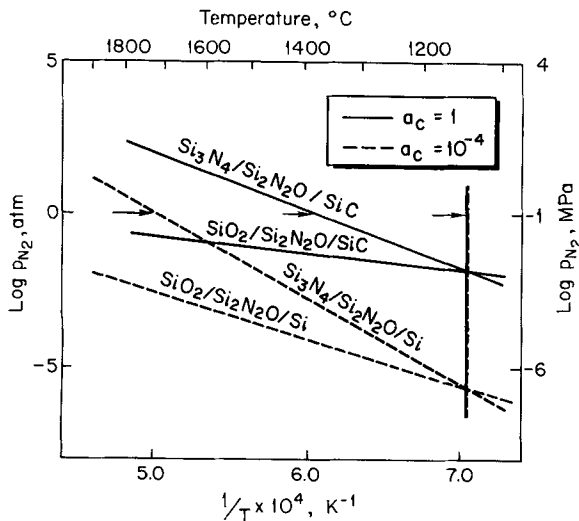


Fig. 4. Changes in equilibrium nitrogen partial pressure at invariant points as a function of temperature at $a_c = 1$ and 10^{-4} .

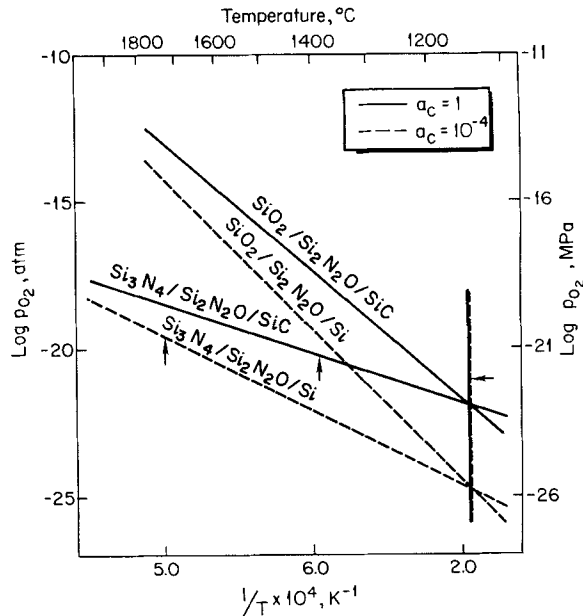


Fig. 5. Changes in equilibrium oxygen partial pressure at invariant points as a function of temperature at $a_c = 1$ and 10^{-4} .

bility, especially at the two invariant points where the effects can be seen simultaneously. A large increase in the nitrogen pressure is required to make Si_3N_4 the stable phase at 1973 K, and avoiding $\text{Si}_2\text{N}_2\text{O}$ phase formation is still difficult with increasing temperature. This effect of temperature is shown more dramatically in Fig. 3 when the carbon activity is reduced to $a_c = 10^{-4}$. These stability diagrams can be a valuable guide in various fields. One such field is ceramics sintering, which we will address in a later section.

(4) Gas Phase

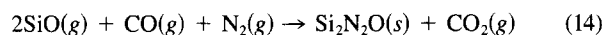
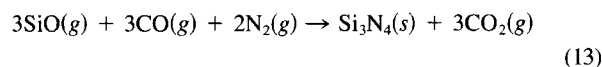
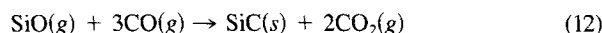
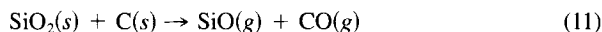
The composition and pressure in the gas phase affects the stability of solid phases, as expected from Table I. Changes in the nitrogen and oxygen pressures at both invariant points for the $\text{Si}_3\text{N}_4/\text{Si}_2\text{N}_2\text{O}/\text{SiC}$ and $\text{SiO}_2/\text{Si}_2\text{N}_2\text{O}/\text{SiC}$ or $\text{Si}_3\text{N}_4/\text{Si}_2\text{N}_2\text{O}/\text{Si}$ and $\text{SiO}_2/\text{Si}_2\text{N}_2\text{O}/\text{Si}$ equilibria are shown as a function of temperature in Figs. 4 and 5, respectively. Both $\text{Si}_3\text{N}_4/\text{Si}_2\text{N}_2\text{O}/\text{SiC}$ and $\text{SiO}_2/\text{Si}_2\text{N}_2\text{O}/\text{SiC}$ or $\text{Si}_3\text{N}_4/\text{Si}_2\text{N}_2\text{O}/\text{Si}$ and $\text{SiO}_2/\text{Si}_2\text{N}_2\text{O}/\text{Si}$ equilibria reach equilibrium with the same gas composition at 1417.8 K, as shown in Figs. 4 and 5.

The stability diagram at 1417.8 K is shown in Fig. 6. The phase stability is governed by the following reaction:



Hence, the silicon oxynitride ($\text{Si}_2\text{N}_2\text{O}$) phase is present on the same line at both carbon activities regardless of nitrogen and oxygen pressures until the SiC or $\text{Si}(s)$ phase appears at lower nitrogen pressures for $a_c = 1$ and 10^{-4} , respectively.

All SiC , Si_3N_4 , and $\text{Si}_2\text{N}_2\text{O}$ formations from SiO_2 occur via intermediate $\text{SiO}(g)$ formation, and a high-temperature decomposition of Si_3N_4 is also related to $\text{SiO}(g)$ as



Therefore, the partial pressure of SiO in the gas phase is closely related to phase stability and materials processing.

The $\text{Si}_3\text{N}_4/\text{Si}_2\text{N}_2\text{O}/\text{SiC}$ and $\text{SiO}_2/\text{Si}_2\text{N}_2\text{O}/\text{SiC}$ or $\text{Si}_3\text{N}_4/\text{Si}_2\text{N}_2\text{O}/\text{Si}$ and $\text{SiO}_2/\text{Si}_2\text{N}_2\text{O}/\text{Si}$ equilibria are shown in Fig. 7 as a function of SiO partial pressure and temperature. The SiO pressure in the gas phase in equilibrium with $\text{Si}_3\text{N}_4/\text{Si}_2\text{N}_2\text{O}/\text{SiC}$ is

relatively low — approximately 10^{-5} atm (10^{-6} MPa) at $a_c = 1$ — and increases 1 order of magnitude with the reduction of carbon activity to 10^{-4} . This increase in p_{SiO} is less with increased nitrogen pressure. This implies that the decomposition of Si_3N_4 by a graphite crucible can be reduced by increasing nitrogen pressure and keeping the SiO gas in the crucible by packing it with auxiliary Si_3N_4 powders.

(5) Application as a Guideline

Densification of ceramic powders or composites by solid-phase sintering is a complicated process which involves powder preparation, green compact preparation, and sintering. There has been considerable active research on the parameters in these processes, such as, sintering temperatures, powder sizes, and compositions. Since the gas phase of the sintering process is usually controlled by the flowing gas, the stability diagram is constructed as a function of temperature for known nitrogen pressures and carbon activities. Flowing nitrogen gas is commonly used for silicon

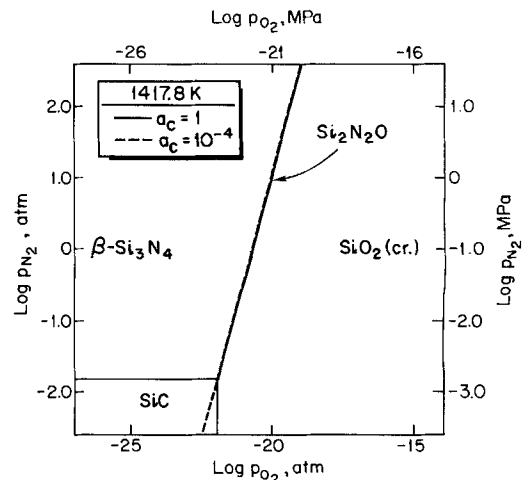


Fig. 6. Phase stability diagram as a function of partial pressures of nitrogen and oxygen at $T = 1417.8$ K and $a_c = 1$ and 10^{-4} .

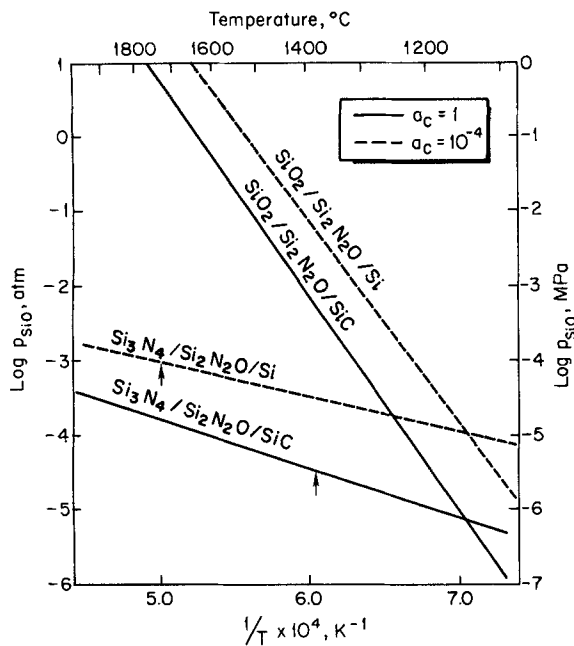


Fig. 7. Changes in equilibrium SiO partial pressure at invariant points as a function of temperature at $a_C = 1$ and 10^{-4} .

nitride sintering. Typical results are shown in Figs. 8 and 9. These results, combined with gas compositions, can be applied as a guideline to sintering both Si₃N₄ and SiC/Si₃N₄ composite.

Figure 8 shows that for a nitrogen pressure of 1 atm (0.10 MPa), Si₃N₄ cannot be sintered without forming β-SiC at temperatures higher than 1374°C, even if the oxygen pressure is kept below 10⁻²⁰ atm (10⁻²¹ MPa). However, if the nitrogen pressure is increased to 10 atm (1.01 MPa), the sintering temperature of Si₃N₄ increases to 1536°C without SiC formation. Furthermore, using a BN crucible instead of a graphite crucible for sintering would increase the possible sintering temperature to more than 1800°C (Fig. 9). For the sintering of Si₃N₄, at each level of carbon activity, the nitrogen pressure must be always higher than the Si₃N₄/Si₂N₂O/SiC line in Fig. 4, whereas the oxygen pressure must be lower than the Si₃N₄/Si₂N₂O/SiC line in Fig. 5. If a carbon container is used for sintering Si₃N₄ at 1700°C, nitrogen pressure as high as 70 atm (7 MPa) is required. Appropriate nitrogen pressures are much higher at higher temperatures. If the activity of carbon is reduced to $a_C = 10^{-4}$, however, Si₃N₄ can be sintered with atmospheric nitrogen pressure at 1700°C.

On the other hand, the SiC/Si₃N₄ matrix composite should be sintered at conditions for which the two phases coexist. Therefore, the carbon activity, the nitrogen pressure, and the gas phase should be well controlled. For instance, Si₃N₄ and SiC are in equilibrium at $p_{N_2} = 1.48$ atm (0.15 MPa) and $p_{O_2} < 7.41 \times 10^{-21}$ atm (7.59×10^{-22} MPa) at 1673 K when a graphite crucible is used, whereas the equilibrium conditions change to $p_{N_2} = 70.79$ atm (7.24 MPa) and $p_{O_2} < 2.40 \times 10^{-19}$ atm (2.45×10^{-20} MPa) at 1973 K (Fig. 2). Nitrogen pressure must be increased almost 50 times with an increase of 300°C in the sintering temperatures. If the nitrogen pressure is lower than the values at SiC/Si₃N₄ equilibrium, the SiC phase becomes more stable and the Si₃N₄ matrix would be deteriorated. When the composite is sintered in a graphite crucible under 1 atm (0.10 MPa) of nitrogen gas flow, the sintering temperature should be close to 1374°C, whereas it can be increased to 1536°C when sintering is conducted at a high nitrogen pressure of 10 atm (1.01 MPa).

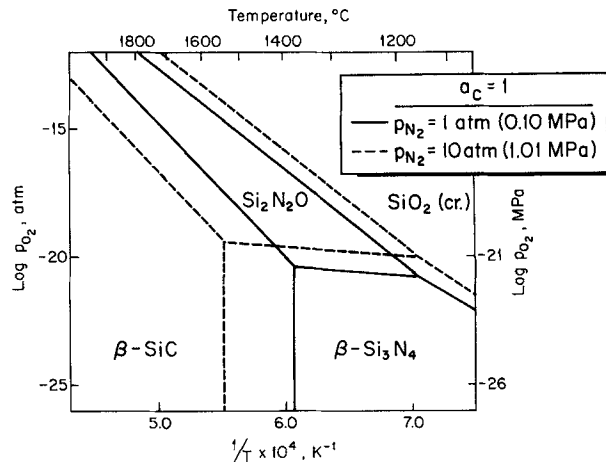


Fig. 8. Phase relationships in the Si-C-N-O system as a function of oxygen partial pressure and temperature at $a_C = 1$, $p_{N_2} = 1$ atm (0.10 MPa), and $p_{N_2} = 10$ atm (1.01 MPa).

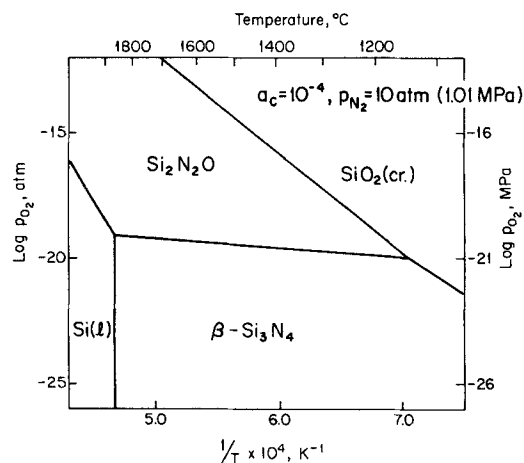


Fig. 9. Phase relationships in the Si-C-N-O system as a function of oxygen partial pressure and temperature at $a_C = 10^{-4}$ and $p_{N_2} = 10$ atm (1.01 MPa).

Reducing carbon activity would allow an increase in the sintering temperature. However, reducing the carbon activity too much would introduce metallic Si formation and increase the possibility of SiO₂ phase formation. If the carbon activity is reduced as low as $a_C = 10^{-4}$, the SiC phase will deteriorate and the metallic Si phase will be formed in a composite sintered at 1870°C, even when the nitrogen pressure is 10 atm (1.01 MPa).

References

- ¹J. Weiss, H. L. Lukas, J. Lorenz, G. Petzow, and H. Krieg, "Calculation of Heterogeneous Phase Equilibria in Oxide-Nitride Systems," *CALPHAD: Comput. Coupling Phase Diagrams Thermochem.*, 5 [2] 125-40 (1981).
- ²J. Weiss, H. L. Lukas, and G. Petzow, "Calculation of Phase Equilibria in Systems Based on Si₃N₄," pp. 77-87 in *Progress in Nitrogen Ceramics*, Edited by F. L. Riley. Martinus Nijhoff, The Hague, Netherlands, 1983.
- ³E.-Th. Henig, H. L. Lukas, and G. Petzow, CALPHAD VII Meeting, Stuttgart, FRG, April 1978, extended abstract pp. 235-44, 1978.
- ⁴G. Eriksson, "Thermodynamic Studies of High-Temperature Equilibria," *Chem. Scr.*, 8, 100-103 (1975).
- ⁵JANAF Thermochemical Tables, 3d ed., American Chemical Society and American Institute of Physics for National Bureau of Standards, 1986.
- ⁶A. Hendry, "Thermodynamics of Silicon Nitride and Oxynitride," pp. 183-84 in *Nitrogen Ceramics*, Edited by F. L. Riley. Noordhoff International, Leyden, Netherlands, 1977.